Structural and electrical investigation of Cobalt doped NiO_x/perovskite interface for efficient inverted solar cells

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Table S1. Grain sizes (nm) of the pure NiO_x and different percentage Co doped nanoparticles, obtained from XRD measurement using the Debye-Scherrer formula $D_{XRD} = 0.89 \lambda / \beta \cos\theta$, where λ is the incident X-ray wavelength (1.54 A), θ is the Bragg diffraction angle, β is the radian-based full width at half-maximum (FWHM) intensity of the peaks belonging to the XRD patterns in Figure 3a.

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	NiO _x	0.75mol %	1mol %	1.25mol %	2.5mol %	5mol %
Grain size	17.1±0.4	12.4±0.3	11.9±0.2	12.1±0.2	12.3±0.3	11.5±0.2

a)





Element	Weight%	Atomic%	Compd%	Formula
Co K	0.00	0.00	0.00	CoO
Ni K	78.58	50.00	100.00	NiO
0	21.42	50.00		
Totals	100.00			



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Element	Weight%	6 Atomi	c% Comp	d% For	mula		

0.17	0.00	0.25	0.70	0.0	
COK	0.55	0.35	0.70	C00	
Ni K	78.03	49.65	99.30	NiO	
0	21.41	50.00			
Totals	100.00				





Element	Weight%	Atomic%	Compd%	Formula
Co K Ni K O Totals	0.92 77.66 21.41 100.00	0.58 49.42 50.00	1.17 98.83	CoO NiO

d)



Element	Weight%	Atomic%	Compd%	Formula
Co K Ni K O Totals	1.09 77.50 21.41 100.00	0.69 49.31 50.00	1.38 98.62	CoO NiO

e)



6 1 2 3 4 Full Scale 4954 cts Cursor: 4.337 (48 cts) 5

Element	Weight%	Atomic%	Compd%	Formula
Co K Ni K O Totals	2.09 76.49 21.41 100.00	1.33 48.67 50.00	2.66 97.34	CoO NiO

f)





Element	weight%	Atomic%	Compa%	Formula
Co K	3.91	2.48	4.97	CoO
Ni K	74.68	47.52	95.03	NiO
0	21.41	50.00		
Totals	100.00			

Figure S1. EDS spectra for NiO_x and Co-NiO_x nanoparticles and quantitative analysis for each element (Ni, Co, O). a) NiO_x. b) 0.75 mol% Co-NiO_x. c) 1 mol% Co-NiO_x. d) 1.25 mol% Co-NiO_x. e) 2.5 mol% Co-NiO_x. f) 5 mol% Co-NiO_x.



Figure S2. Perovskite grain size statistical distributions of the film deposited on the NiO_x with and without Co doping at different percentage (from 0.75 mol% to 5 mol%). The grain size is calculated with the SEM ruler for 40 grains of each kind of sample.

substrate	(110)	(220)	(110)/(220)
NiO _x	563	288	1.95
Co 0.75%	699	285	2.45
Co 1%	584	276	1.11
Co 1.25%	630	287	2.19
Co 2.5%	549	282	1.95
Co 5%	396	226	1.75

Table S2. Intensity of the XRD perovskite peaks (counts) and ratio between the intensitity of the peaks 110 (14.2 °) and 220 (28.5 °).



Figure S3. Statistical analysis of a) V_{oc} b) FF, c) J_{sc} , and d) PCE of 80 perovskite solar cells fabricated with 0-75-5% mol% Co-NiO_x and NiO_x.



Figure S4. Recorded photocurrent at maximum power point J_{MPP} of the champion devices in the case of control NiOx and 0.75 mol% Co-NiOx based cells.

Table S3. Photoluminescence time decay parameters $\tau 1$ and $\tau 2$ and their average.						
	τ ₁ (ns)	τ ₂ (ns)	$ au_{\text{average}}$ (ns)			
MAPbl ₃ on ITO	2.3	33	32			
MAPbl ₃ on NiO _x	1.6	20	20			
MAPbl ₃ on 0.75 mol% Co-NiO _x	0.8	10	9.8			
MAPbl ₃ on 1 mol% Co-NiO _x	0.9	9	8.5			
MAPbl ₃ on 1.25 mol% Co-NiO _x	1.8	11	10.3			
MAPbl ₃ on 2.5 mol% Co-NiO _x	2.1	14	12.5			
MAPbl ₃ on 5 mol% Co-NiO _x	1.5	13	11.2			

b) a) 1.2x108 MAPbl₃ ITO PL Intensity (Norm.) - NiOx - 0.75 Mol% Co-NiOx - 1 Mol% Co-NiOx - 1.25 Mol% Co-NiOx - 2.5 Mol% Co-NiOx - 5 Mol% Co-NiOx NiOx 0.75 mol% Co-NiOx 1.0x10⁸ 1.0x10⁻ 8.0x10⁷ 6.0x10⁷ 4.0x10⁷ 1 mol% Co-NiOx 1.25 mol% Co-NiOx 2.5 mol% Co-NiOx 5 mol% Co-NiOx 2.0x10⁷ 0.0 50 100 150 0 200 750 800 85⁰ 700 Decay Time (ns) Wavelength (nm)

Figure S5. a) PL of MAPbI₃ films on top of NiO_x and 0.75-5 mol % Co-NiO_x. The MAPbI₃ on top of glass was used as a reference measurement; b) Time-resolves PL of the corresponding samples.

a) NiOx

b) 0.75 mol % Co-NiOx



Figure S6. Conductive-AFM topographies on ITO substrates of a) pristine NiO_x and b) 0.75 mol% Co-NiO_x.